



3-20-03

2814

EXPRESS MAIL NO. EV207744587US

PTO/SB/21 (08-00)

Please type a plus sign (+) inside this box → ☒

Approved for use through 10/31/2002. OMB 0651-0031

U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number.

**TRANSMITTAL
FORM**(To be used for all correspondence
after initial filing)


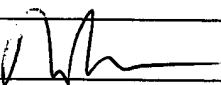
Application Number	10/090,978
Filing Date	March 4, 2002
First Named Inventor	Federico Pio
Group Art Unit	2814
Examiner Name	Douglas A. Wille
Attorney Docket No.	856063.616D1

ENCLOSURES (check all that apply)

- | | | |
|--|--|--|
| <input type="checkbox"/> Fee Transmittal Form | <input type="checkbox"/> Assignment Papers
(for an Application) | <input type="checkbox"/> CD(s), Number
of CD(s) _____ |
| <input type="checkbox"/> Fee Attached | <input type="checkbox"/> Drawing(s) | <input type="checkbox"/> After Allowance
Communication to Group |
| <input checked="" type="checkbox"/> Amendment/Response | <input type="checkbox"/> Request for Corrected Filing
Receipt | <input type="checkbox"/> Appeal Communication to
Board of Appeals and
Interferences |
| <input type="checkbox"/> After Final | <input type="checkbox"/> Licensing-related Papers | <input type="checkbox"/> Appeal Communication to
Group (Appeal Notice, Brief,
Reply Brief) |
| <input type="checkbox"/> Affidavits/declaration(s) | <input type="checkbox"/> Petition | <input type="checkbox"/> Proprietary Information |
| <input type="checkbox"/> Extension of Time Request | <input type="checkbox"/> Petition to Convert to a
Provisional Application | <input type="checkbox"/> Status Letter |
| <input type="checkbox"/> Express Abandonment
Request | <input type="checkbox"/> Power of Attorney,
Revocation, Change of
Correspondence Address | <input checked="" type="checkbox"/> Return Receipt Postcard |
| <input type="checkbox"/> Information Disclosure
Statement; Form PTO-1449 | <input type="checkbox"/> Declaration | <input type="checkbox"/> Additional Enclosure(s)
(please identify below) |
| <input type="checkbox"/> Cited References | <input type="checkbox"/> Statement under 37 CFR
3.73(b) | |
| <input type="checkbox"/> Certified Copy of Priority
Document(s) | <input type="checkbox"/> Terminal Disclaimer | |
| <input type="checkbox"/> Response to Missing Parts
under 37 C.F.R. 1.52 or 1.53 | <input type="checkbox"/> Small Entity Statement | |
| <input type="checkbox"/> Response to Missing
Parts/Incomplete Application | <input type="checkbox"/> Request for Refund | |

Remarks

SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT

Individual Name	Robert Iannucci Reg. No. 33,514	 00500 PATENT TRADEMARK OFFICE
Signature		
Date	March 18, 2003	

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231 on the date specified below.

Typed or printed name	***SENT VIA EXPRESS MAIL***	
Signature		Date:

RECEIVED

MAR 24 2003
TECHNICAL
SERVICES CENTER
2800



EXPRESS MAIL NO. EV207744587US
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Federico Pio et al.
Application No. : 10/090,978
Filed : March 4, 2002
For : IMPROVED FIELD-EFFECT TRANSISTOR AND
CORRESPONDING MANUFACTURING METHOD

Examiner : Douglas A. Wille
Art Unit : 2814
Docket No. : 856063.616D1
Date : March 18, 2003

Box Non-Fee Amendment
Commissioner for Patents
Washington, DC 20231

AMENDMENT

Commissioner for Patents:

In response to the Office Action dated December 18, 2002, please amend the application as follows:

In the Claims:

Please amend claims 1-3 and 6-11 to read as follows:

1. (Amended) A field effect transistor integrated on a semiconductor substrate having an active area, the field effect transistor comprising:
- a source region and a drain region formed in the semiconductor substrate;
 - a channel region interposed between said source and drain regions having a predefined nominal width in a first direction that is perpendicular to a second direction that

4/A
S. Mackey
3-25-03

RECEIVED
MAR 24 2003
TECHNOLOGY CENTER 2800